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## Correction: Nanometer-level high-accuracy molding using a photo-curable silicone elastomer by suppressing thermal shrinkage

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Correction for 'Nanometer-level high-accuracy molding using a photo-curable silicone elastomer by suppressing thermal shrinkage' by Katsuo Mogi *et al.*, *RSC Adv.*, 2015, 5, 10172–10177.

The name of the third author is incorrect in the paper. The correct name is 'Takehiko Tsukahara', as shown above.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

